PTO/SB/21 (02-04) Approved for use through 07/31/2006, OMB 0651-0031 U.S. Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it displays a valid OMB control number. A TOP TOP TOP IN Application Number 10/691.353 TRANSMITTAL Filing Date October 22, 2003 **FORM** First Named Inventor KRYLIOUK et al. Art Unit (to be used for all correspondence after initial filing) 2879 **Examiner Name** Attorney Docket Number 5853-415 Total Number of Pages in This Submission **ENCLOSURES** (Check all that apply) After Allowance communication Fee Transmittal Form Drawing(s) to Technology Center (TC) Appeal Communication to Board Licensing-related Papers Fee Attached of Appeals and Interferences Appeal Communication to TC Petition (Appeal Notice, Brief, Reply Brief) Amendment/Reply Petition to Convert to a **Proprietary Information** After Final Provisional Application Power of Attorney, Revocation Status Letter Affidavits/declaration(s) Change of Correspondence Address Other Enclosure(s) (please **Terminal Disclaimer Extension of Time Request** Identify below): PTO/SB/08A&B; 14 References; and 1 Request for Refund **Express Abandonment Request** Postcard. CD. Number of CD(s) Information Disclosure Statement Remarks Certified Copy of Priority Document(s) Response to Missing Parts/ Incomplete Application Response to Missing Parts under 37 CFR 1.52 or 1.53 SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT Firm Neil R. Jetter AKERMAN SENTERFITT Individual name Signature

CERTIFICATE OF TRANSMISSION/MAILING

Date

April 28, 2004

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Signature			Date	April 28, 2004

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

in re Application of: KRYLIOUK et al.

Application No.:

10/691,353

Examiner:

Date Filed:

October 22, 2003

Group:

2879

For:

GAN GROWTH ON SI USING ZNO BUFFER LAYER

CERTIFICATE UNDER 37 CFR 1.8(a)

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Neil R. Jetter

Commissioner for Patents Post Office Box 1450 Alexandria, VA 22313-1450

Date: April 28, 2004

INFORMATION DISCLOSURE STATEMENT

Sir:

Pursuant to the Duty to Disclose under 37 C.F.R. §1.56, Applicants hereby disclose information that may be relevant to the Examiner's consideration of the above-identified application and the patentability of its claims.

In accordance with Rules 56, 97, and 98 of the Rules of Practice in Patent Cases (37 C.F.R. §§ 1.56, 1.97, and 1.98), Form PTO/SB/08A&B and copies of references cited therein are submitted for consideration by the Examiner. While the references provided in this Information Disclosure Statement may be material to patentability pursuant to 37 C.F.R. § 1.56, it is not intended to constitute an admission that any reference referred to herein is prior art for this invention unless specially designated as such. Also, in accordance with 37 C.F.R. §1.97(g), {WP177094;1}

In re Application of: KRYLIOUK et al.

10/691,353

Application No.:

October 22, 2003

Filed: Group Art Unit:

2879

For: GAN GROWTH ON SI USING ZNO BUFFER LAYER

the filing of this Information Disclosure Statement shall not be construed to mean that a search has been made or that no other material information as defined in 37 C.F.R. § 1.56(a) exists.

This Information Disclosure Statement is being filed before the issuance of a first office action on the merits of the application (37 C.F.R. 1.97(b)(3)); therefore, no fee is believed to be due. However, if any fee is due, the Commissioner is authorized to charge any such fee and any additional fees due or credit any overpayment to Deposit Account No. 50-0951.

Respectfully submitted,

Neil R. Jetter, Reg. No. 46,803

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Docket No. 5853-415

PTO/SB/08A (08-03)

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Sheet 1

Under the Paper wo.... PADE Stitute for form 1449/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

Complete if Known				
Application Number	10/691,353			
Filing Date	October 22, 2003			
First Named Inventor	KRYLIOUK et al.			
Art Unit	2879			
Examiner Name		,		
Attomory Docket Number	E0E2 41E			

			U. S. PATEN	T DOCUMENTS		
Examiner Initials*	Cite No.1	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant	
		Number-Kind Code ^{2 (# known)}			Figures Appear	
		US- _{6,030,886}	02/29/2000	Yuri et al.		
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FOREIGN PATENT DOCUMENTS							
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Signature	Considered	

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Substitute for form 1449/PTO		Complete if Known			
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STATEMENT BY APPLICANT			PPLICANT	First Named Inventor	Kryliouk et al.
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Sheet	1	of	2	Attorney Docket Number	5853-415

		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T²
		PEARTON et al., "GaN: Processing, defects, and devices," Journal of Applied Physics, 86:1-78, 1999.	
		PEARTON et al., "Fabrication and performance of GaN electronic devices," Materials Science and Engineering: R: Reports, 30:1-137, 2000.	
·		KIM et al., "Growth of high-quality GaN on Si(111) substrate by ultrahigh vacuum chemical vapor deposition," Applied Physics Letters, 78:2858-2860, 2001.	
		KROST et al., "GaN-Based Devices on Si," Phys. Stat. Sol., 194:361-375, 2002.	
		WANG et al., "Growth of hexagonal GaN on Si(111) coated with a thin flat SiC buffer layer," Applied Physics Letters, 77:1846-1848, 2000.	
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		GU et al., "Role of interfacial compound formation associated with the use of ZnO buffers layers in the hydride vapor phase epitaxy of GaN," Applied Physics Letters, 76:3454-3456, 2000.	
		MOLNAR et al., "Growth of gallium nitride by hydride vapor-phase epitaxy," Journal of Crystal Growth, 178:147-156, 1997.	
		DETCHPROHM et al., "Hydride vapor phase epitaxial growth of a high quality GaN film using a ZnO buffer layer," Appl. Phys. Lett., 61:2688-2690, 1992.	

Examiner	Date	
Signature	Considered	

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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Sheet

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		NON PATENT LITERATURE DOCUMENTS	,			
Examiner Cite Initials* No.		Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.				
		STRITTMATTER et al., "LP-MOCVD growth of GaN on silicon substrates-comparison between A1As and ZnO nucleation layers," Materials Science and Engineering, 59:29-32, 1999.				
		LEE et al., "The Application of a Low Temperature GaN Buffer Layer to Thick GaN Film Growth on ZnO/Si Substrate," Phys. Stat. Sol., 176:583-587, 1999.				
		DEHOFF, R., "Thermodynamics in Materials Science," McGraw Hill, 326-327, 1993.				
,		MOLNAR et al., "GALLIUM NITRIDE THICK FILMS GROWN BY HYDRIDE VAPOR PHASE EPITAXY," Mat. Res. Soc. Symp., 423:221-226, 1996.				

Examiner		Date	
Signature	•	Considered	

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